

[54] FACIAL MASK

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[\*\*] Term: 14 Years

[21] Appl. No.: 639,103

[22] Filed: Aug. 9, 1984

[52] U.S. Cl. .... D28/9; D29/8

[58] Field of Search ..... D28/9, 10, 7, 99; D21/190; D2/79, 233, 234; 2/9, 11, 173, 206, 174; 132/1 R, 7, 9; D29/7, 8

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[57] CLAIM

The ornamental design of a facial mask, substantially as shown.

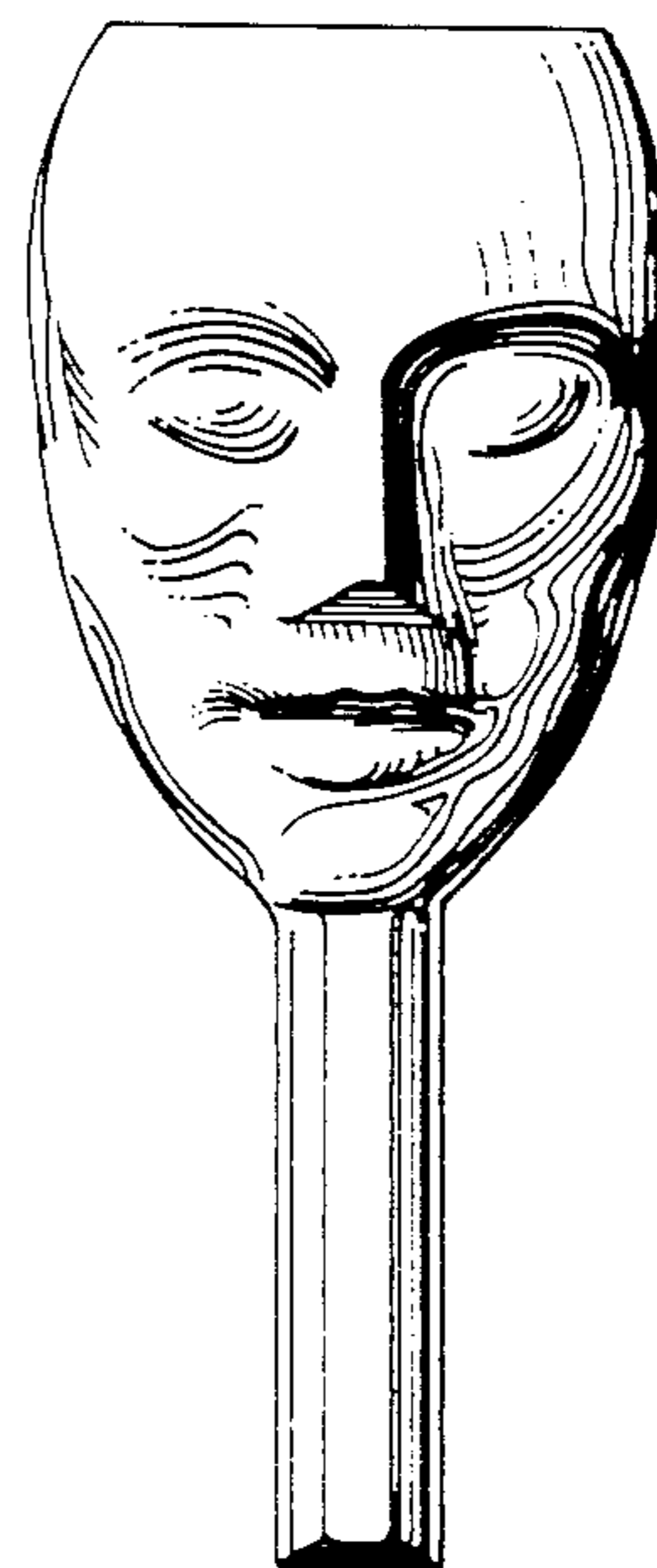
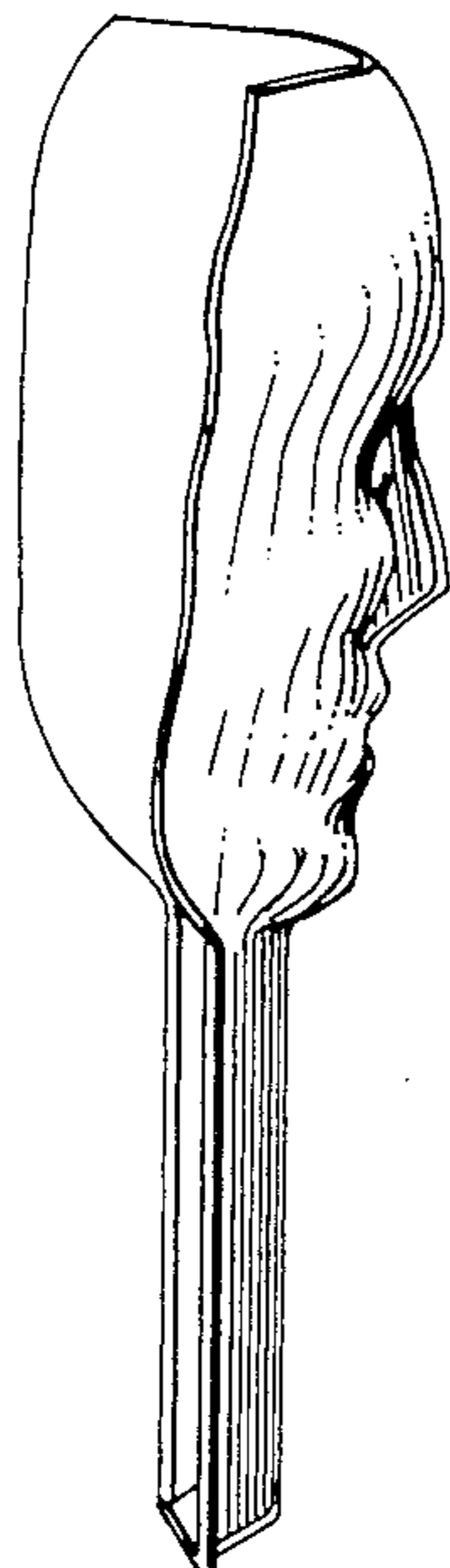
DESCRIPTION

FIG. 1 is a front elevational view of a facial mask showing my new design;

FIG. 2 is a rear elevational view thereof;

FIG. 3 is a right side elevational view thereof, the left side elevational view being a virtual mirror image; and

FIG. 4 is a three quarter left rear view thereof.



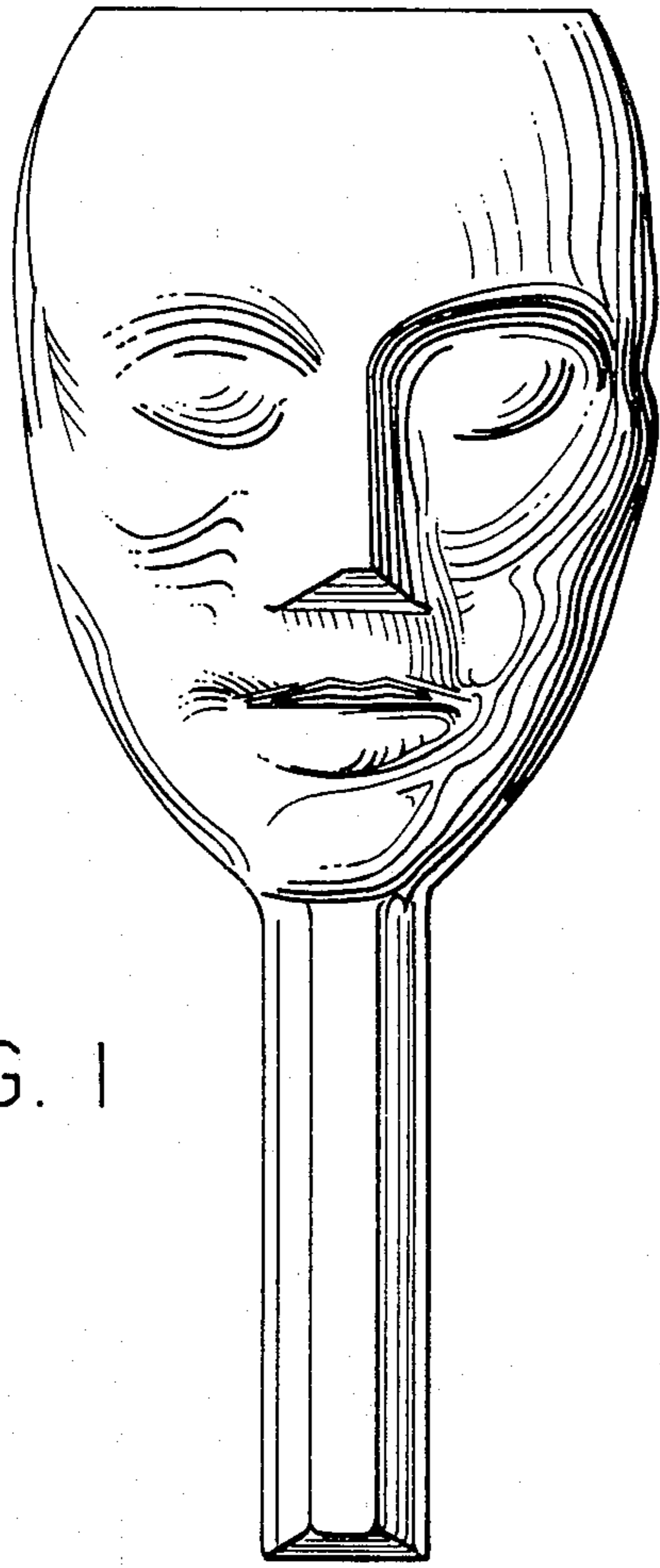


FIG. 1



FIG. 2

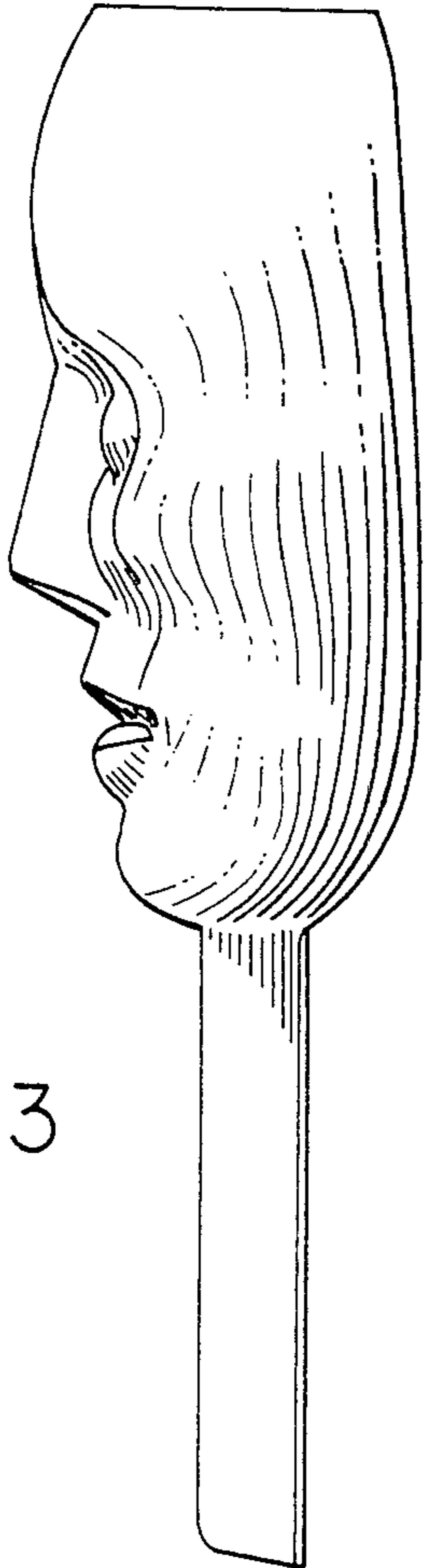


FIG. 3

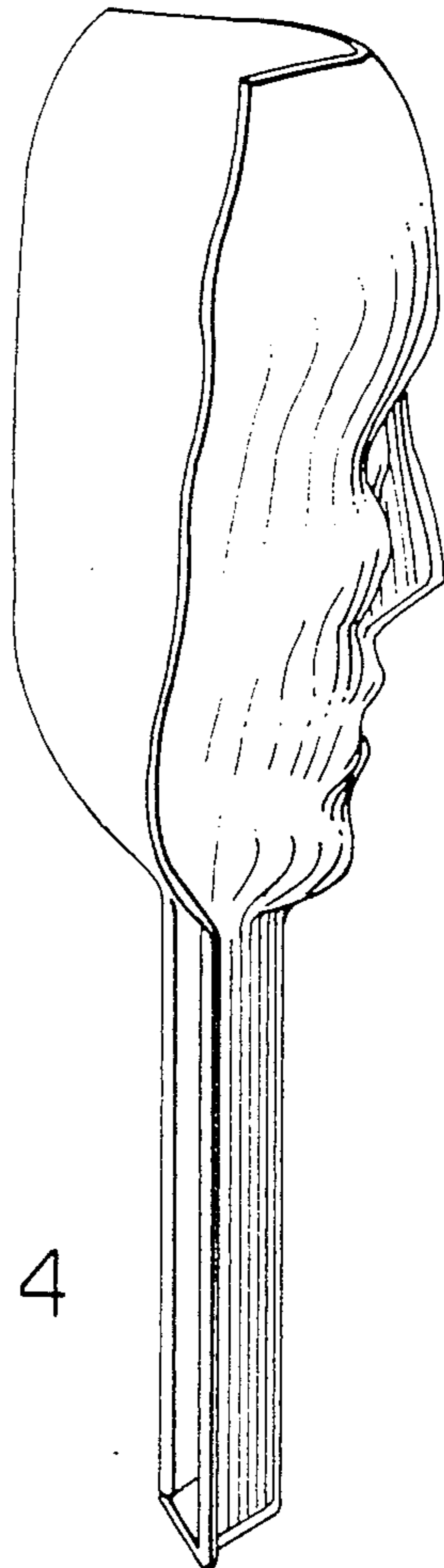


FIG. 4